IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): F.A. Baiocchi et al.

Case:

1-1-36-5

Serial No.:

To Be Assigned

Filing Date:

September 29, 2003

Group: Examiner:

To Be Assigned To Be Assigned

Title:

Metal-Oxide-Semiconductor Device with

Enhanced Source Electrode

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Pursuant to 37 C.F.R. §§1.56, 1.97 and 1.98, Applicants' attorney wishes to bring to the attention of the Patent and Trademark Office the following documents listed on the accompanying Form PTO-1449. A copy of each listed document is enclosed, other than the published U.S. patent document.

U.S. Patent Documents

1. U.S. Patent No. 5,869,875 issued on 02/09/99 to Hebert

Other Documents

1. C.S. Kim et al., "Trenched Sinker LDMOSFET (TS-LDMOS) Structure for High Power Amplifier Application above 2 GHz," International Electron Devices Meeting Proceedings, 2001, pp. 40.2.1-40.2.4.

The filing of this Information Disclosure Statement shall not be construed as a representation that a search has been made, or as an admission that the information cited is considered to be material to patentability, or as a representation that no other material information exists.

Respectfully submitted,

Wayned.El

Date: September 29, 2003

Wayne L. Ellenbogen

Reg. No. 43,602

Attorney for Applicant(s) Ryan, Mason & Lewis, LLP

90 Forest Avenue

Locust Valley, NY 11560

(516) 759-7662

FORM PTO-1449 (MODIFIED)

LIST OF PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT

Examiner

Applicant(s): F.A. Baiocchi et al.

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INITIAL DOCUMENT NO. DATE NAME CLASS/SUBCLASS IF APPROPRIATE 1. 5,869,875 02/09/99 Hebert FOREIGN PATENT DOCUMENTS EXAMINER INITIAL DOCUMENT NO. DATE COUNTRY CLASS/SUBCLASS YES NO OTHER DOCUMENTS EXAMINER OTHER DOCUMENTS	U.S. PATENT DOCUMENTS							
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	40	.2.4.						

Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.

Date Considered